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U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO. IMEC232.001DV1

APPLICATION NO. 10/644,690

BADE WENT FORMATION DISCLOSURE STATEMENT BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)
FILING DATE
August 19, 2003

APPLICANT Stalmans et al.

> GROUP 2812

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